

INFORMATION DISCLOSURE CITATION IN AN APPLICATION (Use several sheets if necessary)	Attorney Docket No.: 8017-1127	Application No.: NEW NONPROVISIONAL
	Applicant: Takahiro ADACHI et al.	
	Filing Date: February 10, 2004	Group Art Unit:

U.S. PATENT DOCUMENTS

Examiner Initial	Document Number	Date	Name	Class	Subclass	Filing date (if appropriate)

FOREIGN PATENT DOCUMENTS

Examiner Initial	Document Number	Date	Country	Class	Subclass	Translation	
						Yes	No
/TB/	2001-203539	7/27/2001	JAPAN			*	
/TB/	2002-299966	10/11/2002	JAPAN			*	
/TB/	2001-53627	2/23/2001	JAPAN			*	
/TB/	2001-274851	10/5/2001	JAPAN			*	
/TB/	2000-228643	8/15/2000	JAPAN			*	

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

EXAMINER: /Tsfaldet Bocure/	DATE CONSIDERED 03/07/2007
--------------------------------	-------------------------------

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.

* Abstract provided for the Examiner's convenience

yr

INFORMATION DISCLOSURE CITATION IN AN APPLICATION (Use several sheets if necessary)		Attorney Docket No.: 8017-1127	Application No.: 10774,462
Applicant: Takahiro ADACHI et al.		Filing Date: February 10, 2004	Group Art Unit: 2816

U.S. PATENT DOCUMENTS

Examiner Initial	Document Number	Date	Name	Class	Subclass	Filing date (if appropriate)

FOREIGN PATENT DOCUMENTS

Examiner Initial	Document Number	Date	Country	Class	Subclass	Translation	
						Yes	No
/TB/	JP 10-322137	12/4/1998	Japan (with English abstract)				

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

EXAMINER: /Tesfaldet Bocure/	DATE CONSIDERED 03/07/2007
--	--------------------------------------

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.